(11) Publication number:

0 184 217

A3

EUROPEAN PATENT APPLICATION

(21) Application number: 85115532.5

(22) Date of filing: 06.12.85

(5) Int. Ci.³: **H 01 J 61/10** H 01 J 61/72

(30) Priority: 06.12.84 US 678958

(43) Date of publication of application: 11.06.86 Bulletin 86/24

88 Date of deferred publication of search report: 02.11.88

84 Designated Contracting States: BE DE FR GB NL

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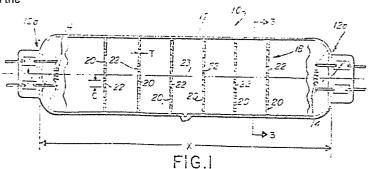
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[54] Low pressure arc discharge tube having increased voltage.

57 A low pressure arc discharge tube having structural means located within the envelope for raising the voltage across the arc tube. The structural means comprises at least one partition extending across the arc tube and having a dimension which is less than the electron energy relaxation distance of the arc discharge tube. Each of the partitions has at least one aperture therein which constricts the arc within the tube.





EUROPEAN SEARCH REPORT

Application Number

EP 85 11 5532

Category	Citation of document with indic	ation, where appropriate.	Relevant	CLASSIFICATION OF TH	
	of relevant passa	ges	to claim	APPLICATION (Int. Cl.4)	
Х	DE-C- 912 243 (SKAU * Whole document *	PY)	1-4,6-8	H 01 J 61/10 H 01 J 61/72	
A	FR-A-1 162 139 (THOM * Page 1, left-hand c 2; figures 2-8 *	SON) olumn, paragraph	11-13		
			-	TECHNICAL FIELDS SEARCHED (Int. Cl.4)	
				H 01 J 61/00	
	The present search report has been	drawn up for all claims			
Place of search THE HAGUE		Date of completion of the search 30–08–1988	CENTI	Examiner TMAYER	
CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure		E: earlier patent do after the filing d D: document cited i L: document cited fo	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons &: member of the same patent family, corresponding		